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Electron transporting unit linked multifunctional Ir(III) complex: A promising strategy to improve the performance of solution-processed phosphorescent organic light-emitting diodes†

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The oxadiazole based electron transporting (ET) unit was glued to the heteroleptic Ir(III) complex (TPQIr-ET) and used as a dopant for phosphorescent organic light-emitting diodes (PhOLEDs). It shows superior device performance than the dopant (TPQIr) without ET unit due to the balanced charge carrier injection by ET unit, which has never been observed before in PhOLEDs.

The development of high performance solution-processed phosphorescent organic light-emitting diodes (PhOLEDs) have attracted significant research interest owing to their foreseeable impact in inexpensive large area and flexible display devices.[1] PhOLEDs using Ir(III) complexes as an emitters have drawn more attention due to their potential of 100% internal quantum efficiency via harvesting of both singlet and triplet excitons.[2] Among the phosphorescent emitters, homoleptic and heteroleptic cyclometalated Ir(III) complexes are still the most promising phosphors due to their relatively short triplet lifetimes, high quantum yields, and emission wavelength tunability from blue to deep-red.[3-5] Particularly, the color of the emitters can be tuned by introduction of electron-donating or electron-accepting units and increasing or decreasing the extended π-conjugation in the ligands. In contrast, the performance of the particular emitter depends mainly on its interaction with the host materials, which are hole[6] or electron[7] or mixture of hole and electron transporting[8] or bipolar materials.[9] Generally, the similar structural features of the ligands of emitter and host materials facilitate charge injection and transport ability of the resultant PhOLEDs. For example, Ir(III) complexes with carbazole based ligands as dopant and CBP [4,4'-di(carbazole-9-yl)biphenyl] or PVK [poly(N-vinylcarbzole)] as host materials enhance the hole injection and transport ability of the PhOLEDs.[10] Particularly, upon using either of hole transporting or electron transporting (ET) single host materials, there has been a charge imbalance due to the existence of higher hole or electron mobility.[11] Alternatively, the mixed and/or bipolar host materials can provide a more balanced injection and transport of both the charge carriers due to the balance between the charges.[8,9] Thus, we glued the oxadiazole based ET unit to the ancillary ligand of heteroleptic Ir(III) complex by ether linkage to analyze its effect on the device performance without changing the

luminance maximum. Here, the ET unit may further improved the balance between the charges.

For this purpose, the thiophene-phenylquinoline (TPQ) based main ligand and the picolinic acid with oxadiazole based ET unit as an ancillary ligand for heteroleptic Ir(III) complex, **TPQIr-ET**, was successfully designed and synthesized; for comparison, similar Ir(III) complex without the ET group, **TPQIr**, was also synthesized. The structure of **TPQIr-ET** and **TPQIr** are shown in Scheme 1. The solution-processed deep-red PhOLEDs were fabricated using these Ir(III) complexes as dopant and tris(4-carbazoyl-9-ylphenyl)amine (TCTA)/1,3,5-tri(1-phenyl-1H-benzo[d]imidazol-2-yl)phenyl (TPBi) or TCTA/1,3-bis(5-(4-tert-butylphenyl)-1,3,4-oxadiazol-2-yl)benzene (OXD-7) as mixed-host materials with the configuration of ITO/PEDOT:PSS/TCTA:TPBi (1:1) or TCTA:OXD-7 (1:1):dopant/TmPyPB/LiF/Al. The poly(3,4-ethylenedioxythiophene):poly(styrenesulfonate) (PEDOT:PSS) and 3,3'-[5'-[3-(3-pyridinyl)phenyl][1,1':3',1"-terphenyl]-3,3"-diyl]bispyridine (TmPyPB) were used as a hole transporting layer and electron transporting layer, respectively. The devices based **TPQIr-ET** shows the EQE of 20.59%, which is the highest values reported to date for red PhOLEDs prepared by a solution-process (Table S2). Additionally, we found that the **TPQIr-ET** shows 25% higher external quantum efficiency (EQE) than the **TPQIr** due to the balanced charge carrier injection by ET group.
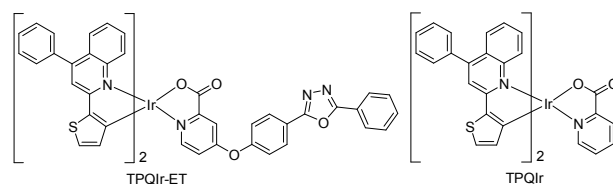
Scheme 1. Structure of **TPQIr-ET** and **TPQIr**

Both **TPQIr-ET** and **TPQIr** were synthesized in quantitative yields (Scheme S1, ESI†) and confirmed their structures by ^{1}H, ^{13}C NMR, elemental analysis, and high resolution mass spectroscopy (details are in the ESI†). They possess an excellent solubility in common organic solvents making them a suitable candidate for solution-processed PhOLEDs. Thermal gravimetic analysis under an N_2 atmosphere (Fig. S1, ESI†) reveals the onset

decomposition temperature at 349 and 343 °C for **TPQIr-ET** and **TPQIr**, respectively, indicating their high thermal stability. Differential scanning calorimetry analysis (Fig. S2, ESI†) reveals the glass transition (T_g) at 202 and 213 °C for **TPQIr-ET** and **TPQIr**, respectively, indicating their amorphous nature.

The UV-visible absorption and photoluminescence (PL) spectra of **TPQIr-ET** and **TPQIr** in methylene chloride (MC) solution at room temperature are shown in Fig. 1a. Both **TPQIr-ET** and **TPQIr** show two absorption bands; the broad bands between 550-450 nm corresponding to the admixture of singlet and triplet metal to ligand charge transfer (^{1}MLCT, ^{3}MLCT) transitions and the bands between 470-330 nm with a peak at 350 nm are attributed to the spin allowed $\pi-\pi^*$ transitions of the ligands. This indicates that the ET group in the **TPQIr-ET** does not give any significant effect on the ground state energy levels of Ir(III) complexes because the ET group linked to the ancillary ligand by ether linkage, which prevents the extended π-conjugation between them. Additionally, the PL patterns of **TPQIr-ET** and **TPQIr** are also exactly similar with a maximum at 612 nm as shown in Fig. 1a and the quantum yield of 0.25 and 0.23, respectively. It also reveals that the ET group can not give any significant changes in the excited state of Ir(III) complex, which leads to similar emission pattern and maxima.
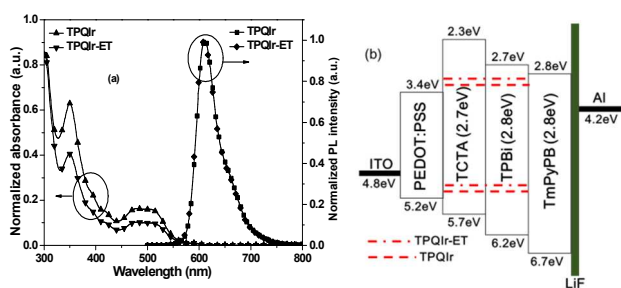

Fig. 1 (a) UV-visible and PL spectra of **TPQIr** and **TPQIr-ET** in MC and (b) energy level diagram of the materials.

In order to find highest occupied molecular orbital (HOMO) and lowest unoccupied molecular orbital (LUMO) energy levels, the cyclic voltammetry experiments were carried out for **TPQIr-ET** and **TPQIr** in MC solution (Fig. S3, ESI†). Both the Ir(III) complexes exhibited a well-defined reversible redox process. The HOMO energy levels were calculated from the onset of oxidation potentials and found to be -5.26 and -5.24 eV for **TPQIr-ET** and **TPQIr**, respectively. The LUMO levels were calculated from their HOMO levels and optical band gaps were determined from their absorption edges and found to be -3.07 and -3.08 eV for **TPQIr-ET** and **TPQIr**, respectively. As shown in Fig. 1b, the HOMO and LUMO energy levels of Ir(III) complexes are well matched with the adjacent layers of devices. Finally, from the both optical and electrochemical properties, it was found that the introduction of the oxadiazole based ET group in **TPQIr-ET** does not give any significant influence on the energy levels of Ir(III) complexes. Density functional theory calculations were performed to gain an insight into the photophysical properties of both Ir(III) complexes. Becke's three parameterized Lee−Yang−Parr exchange functional (B3LYP) and a suite of Gaussian 09 programs were employed.[12] Except for treating Hay–Wadt effective core potential of a double zeta basis set (LANL2DZ) on Ir(III) metal, split valance 6-311+G** basis sets were used. The HOMOs are largely distributed over the Ir(III) metal and one of the TPQ based main ligands while LUMOs are predominant on the ancillary ligand (Fig. S4, ESI†). These results show that the MLCT is likely to contribute to the transition properties. The calculated HOMO-LUMO energy levels of **TPQIr-ET** and **TPQIr** were 3.15 and 3.16 eV, which are almost

similar to the experimentally determined energy levels of 3.09 and 3.12 eV, respectively. Particularly, the ET group in **TPQIr-ET** can not involve in any of the energy levels.

Table 1. Device characteristics of **TPQIr-ET** and **TPQIr** with various ratios of mixed host systems.

Device	Host	Dopant	V_{on} [V]	EQE (%)	η_c [cd/A]	η_p [lm/W]	L_{max} [cd/m²]
I	TCTA/ TPBi	TPQIr	6.6	15.28	13.69	2.87	2013
II	TCTA/ OXD-7	TPQIr	6.3	5.92	5.09	1.66	3013
III	TCTA/ TPBi	TPQIr-ET	6.0	20.59	17.20	6.72	1334
IV	TCTC/ OXD-7	TPQIr-ET	5.7	7.40	6.54	1.31	2661

To demonstrate the potential of the ET group in **TPQIr-ET** on the device performance, the solution-processed deep-red PhOLEDs (Fig. S5, ESI†) with various combinations of host and dopant materials (I, II, III, and IV), as shown in Table 1, were fabricated with the configuration of ITO/PEDOT:PSS/TCTA:TPBi or TCTA:OXD-7:dopant/TmPyPB/LiF/Al. Here, the emitting layer (EML) consist of 1:1 ratio of TCTA and TPBi or OXD-7 with 8wt% of the **TPQIr-ET** or **TPQIr**. Fig. 2 shows the current density-voltage-luminance (I-V-L) and luminance efficiency-current density-power efficiency (LE-I-PE) curves of the all the devices and the data are summarized in Table 1.
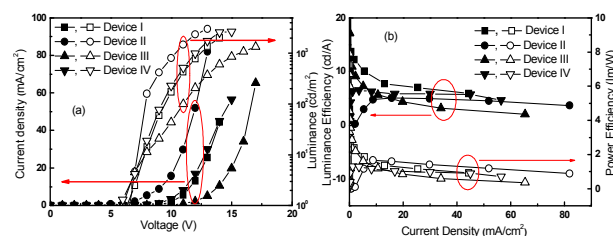

Fig. 2 (a) Current density-voltage-luminance (I-V-L) and (b) luminance efficiency-current density-power efficiency (LE-I-PE) curve of the devices based on **TPQIr-ET** and **TPQIr** dopants.

The device I shows the current efficiency of 13.69 cd/A and the EQE of 15.28%, which are around 70% higher than that of the device II, current efficiency of 5.09 cd/A and the EQE of 5.92%, respectively. It reveals that the TPBi has a balanced ET property with the hole transporting host TCTA than the OXD-7. Similarly, the device III shows the current efficiency of 17.20 cd/A and the EQE of 20.59%, which are around 60% higher than the device IV, current efficiency of 7.40 cd/A and the EQE of 6.54%, respectively. Although both TPBi and OXD-7 have a good ET nature, the TPBi based devices show better device performance than that of OXD-7. This can be explained by the nature of the morphology engineering between TPBi or OXD-7 with TCTA (vide infra). Interestingly, the **TPQIr-ET** based devices shows improved device performance than the **TPQIr** due to the introduction of the ET group in the dopant materials, which exists only 8wt% of the dopant in EML, has a strong influence on balanced charge carrier injection. The hole transporting and ET properties of **TPQIr-ET** and **TPQIr** were further studied by fabricating hole and electron only devices (Fig. S6, ESI†). The mobility data are extracted in Table S1 (ESI†). It is obvious that the balance between hole and electron transport properties of **TPQIr-ET** are higher than that of **TPQIr** due to the presence of ET group.

The morphology engineering between the host and dopant materials can be analyzed by atomic force microscopy (AFM). AFM topographic images of 40 nm thick mixed-host TCTA:TPBi (1:1)

and TCTA:OXD-7 (1:1) with 8wt% of **TPQIr** doped EML film are shown in Fig. 3a and 3b, respectively. Unexpectedly, the TCTA:TPBi based mixed-host system shows higher root means square surface roughness value (0.76 nm) than that of the TCTA:OXD-7 (0.55 nm). This is due to the fact the TCTA and TPBi have a disk like structure, which may be arranged in a columnar manner but in the case of TCTA and OXD-7 based system may have an inter digitated future due to rod like nature of OXD-7. Thus, the balanced charge carrier injection is more feasible in the TCTA:TPBi system than the TCTA:OXD-7. A similar trend has also been observed for **TPQIr-ET** (Fig. 3c and 3d). Interestingly, the introduction of the ET group in dopant materials improves the efficiency without engineering the morphology of the EML of devices.
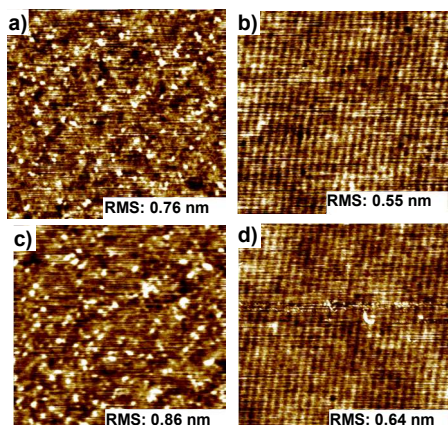

Fig. 3 AFM topographic images of (a) TCTA:TPBi:TPQIr, (b) TCTA:OXD-7:TPQIr, (c) TCTA:TPBi:TPQIr-ET, and (d) TCTA:OXD-7:TPQIr-ET based devices

As shown in Fig. 4a, all the devices exhibited narrow deep-red electroluminescence (EL) spectra, which are similar to the PL spectra of the dopants. It suggests that the emission is mainly originates from the triplet states of the Ir(III) complexes regardless of the nature of the host materials. As shown in Fig. 4b, the devices I, II, III, and IV emit a deep-red light with the CIE coordinates of (0.671, 0.326), (0.671, 0.326), (0.673, 0.323), and (0.672, 0.325), respectively.
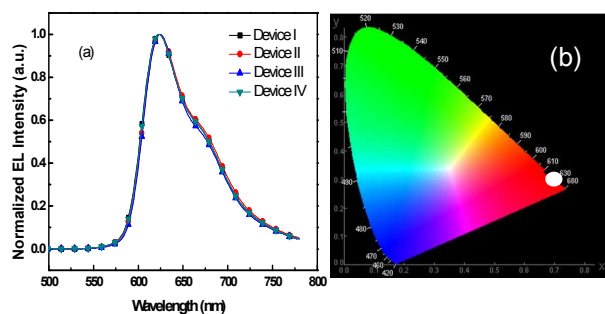

Fig. 4 (a) EL spectra and (b) CIE coordinate of of devices I, II, III, and IV.

In summary, two heteroleptic Ir(III) complexes, **TPQIr-ET** and **TPQIr** were designed, synthesized, and applied as a dopant for solution-processed deep-red PhOLEDs. Here, we introduced the ET group to the ancillary ligand of dopant materials to improve the balanced charge carrier injection in the devices. As a result, **TPQIr-ET** shows the EQE of 20.59%, which is 25% higher than that of the

TPQIr. This work provides the first successful example of the use of a dopant with the ET group in PhOLEDs to realize efficient device performance. This also opens up new prospective in the designing of new phosphorescent emitters for efficient solution-processed PhOLEDs.

Acknowledgments

Notes and references

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[†]Electronic Supplementary Information (ESI) available: Experimental details, thermal stabilities and additional figures See DOI: 10.1039/c000000x/

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